

L Number	Hits	Search Text	DB	Time stamp
1	1305	(427/585,593,596).CCLS.	USPAT; US-PGPUB	2004/07/20 08:57
2	771	(427/255.28,255.39).CCLS.	USPAT; US-PGPUB	2004/07/20 08:57
3	1727	(427/372.2).CCLS.	USPAT; US-PGPUB	2004/07/20 08:58
4	556	(423/490,497).CCLS.	USPAT; US-PGPUB	2004/07/20 08:58
5	4504	(118/715,725,728).CCLS.	USPAT; US-PGPUB	2004/07/20 08:58
6	1221	(204/192.1,192.11,192.16).CCLS.	USPAT; US-PGPUB	2004/07/20 08:58
7	9759	((427/585,593,596).CCLS.) ((427/255.28,255.39).CCLS.) ((427/372.2).CCLS.) ((423/490,497).CCLS.) ((118/715,725,728).CCLS.) ((204/192.1,192.11,192.16).CCLS.)	USPAT; US-PGPUB	2004/07/20 08:59
8	1	((427/585,593,596).CCLS.) or ((427/255.28,255.39).CCLS.) or ((427/372.2).CCLS.) or ((118/715,725,728).CCLS.) or ((204/192.1,192.11,192.16).CCLS.)) and ((423/490,497).CCLS.)	USPAT; US-PGPUB	2004/07/20 08:59
9	8	((427/585,593,596).CCLS.) ((427/255.28,255.39).CCLS.) ((427/372.2).CCLS.) ((423/490,497).CCLS.) ((118/715,725,728).CCLS.) ((204/192.1,192.11,192.16).CCLS.)) and (((MgF ₂ or "MgF. _{sub.2} " or (magnesium near ₂ fluoride) or (magnesium near ₂ halide) or (metal near ₂ fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity) same (purity or pure or impure or impurit\$3))	USPAT; US-PGPUB	2004/07/20 09:05
10	57	((MgF ₂ or "MgF. _{sub.2} " or (magnesium near ₂ fluoride) or (magnesium near ₂ halide) or (metal near ₂ fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity) and (((MgF ₂ or "MgF. _{sub.2} " or (magnesium near ₂ fluoride) or (magnesium near ₂ halide) or (metal near ₂ fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3))	USPAT; US-PGPUB	2004/07/20 09:20

11	49	((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3))) not (((427/585,593,596).CCLS.) ((427/255.28,255.39).CCLS.) ((427/372.2).CCLS.) ((423/490,497).CCLS.) ((118/715,725,728).CCLS.) ((204/192.1,192.11,192.16).CCLS.)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity) same (purity or pure or impure or impurit\$3)))	USPAT; US-PGPUB	2004/07/20 09:06
12	51	((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (purity or pure or impure or impurit\$3))) not (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (purity or pure or impure or impurit\$3))) not (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3)))	USPAT; US-PGPUB	2004/07/20 09:21
13	26	((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (purity or pure or impure or impurit\$3))) not (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3)))	USPAT; US-PGPUB	2004/07/20 09:16
14	3	((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity)) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3)))	EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:20

15	153	((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (purity or pure or impure or impurit\$3))	USPAT; US-PGPUB	2004/07/20 09:23
16	18	((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (purity or pure or impure or impurit\$3))	EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:21
17	15	(((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (purity or pure or impure or impurit\$3)) not (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (density or dense or nonporous or porous or porosity) and (((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride)) with (coat\$3 or film or layer or deposit\$3 or \$4CVD or apply\$3 or sputter\$3 or \$3PVD)) same (purity or pure or impure or impurit\$3)))	EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:21
18	210	((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity) same (anneal\$3 or bake or baked or baking or heat\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:24
19	101	(((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity or denser or densi\$8) with (anneal\$3 or bake or baked or baking or heat\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:26
20	5	(((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity or denser or densi\$8) with (anneal\$3 or bake or baked or baking or heat\$3)) and (((427/585,593,596).CCLS.) ((427/255.28,255.39).CCLS.) ((427/372.2).CCLS.) ((423/490,497).CCLS.) ((118/715,725,728).CCLS.) ((204/192.1,192.11,192.16).CCLS.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:25

21	96	((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity or denser or densi\$8) with (anneal\$3 or bake or baked or baking or heat\$3))) not (((((MgF2 or "MgF.sub.2" or (magnesium near2 fluoride) or (magnesium near2 halide) or (metal near2 fluoride))) same (density or dense or nonporous or porous or porosity or denser or densi\$8) with (anneal\$3 or bake or baked or baking or heat\$3))) and (((427/585,593,596).CCLS.) ((427/255.28,255.39).CCLS.) ((427/372.2).CCLS.) ((423/490,497).CCLS.) ((118/715,725,728).CCLS.) ((204/192.1,192.11,192.16).CCLS.)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/20 09:27
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